 -	Hits	Search Text	DB	Time stamp
L Number	nics	Sealch lext		
Number 1	436	"low k" same (ammonia or NH3 or	USPAT;	2003/04/20
1	750	"NH.sub.3" or CO or "carbon monoxide" or	EPO; JPO;	13:58
		oxygen or "o.sub.2" or nitrogen or	IBM_TDB	
		"N. sub. 2")	_	
2	283	("low k" same (ammonia or NH3 or	USPAT;	2003/04/20
-		"NH.sub.3" or CO or "carbon monoxide" or	EPO; JPO;	13:09
		oxygen or "o.sub.2" or nitrogen or	IBM_TDB	
		"N.sub.2")) and 438/\$.ccls.		
3	49349	(ammonia or NH3 or "NH.sub.3") same (CO	USPAT;	2003/04/20
		or "carbon monoxide" or oxygen or	EPO; JPO;	14:21
· 1		"o.sub.2")	IBM_TDB	2002/04/20
4	1482	(parylene or benzocyclobuthene or BCB or	USPAT;	2003/04/20
,		HSG or "carbon doped oxide") same	EPO; JPO;	14:02
İ		(etch\$3 or remov\$3)	IBM_TDB USPAT;	2003/04/20
5	62	((ammonia or NH3 or "NH.sub.3") same (CO	EPO; JPO;	14:07
ļ		or "carbon monoxide" or oxygen or	IBM TDB	13.07
		"o.sub.2")) and ((parylene or	1011_100	
		benzocyclobuthene or BCB or HSG or "carbon doped oxide") same (etch\$3 or		
		remov\$3))		
_	22	((ammonia or NH3 or "NH.sub.3") same (CO	USPAT;	2003/04/20
6	22	or "carbon monoxide" or oxygen or	EPO; JPO;	14:15
		"o.sub.2")) same "low k"	IBM TDB	
7	163		USPAT;	2003/04/20
′		or "carbon monoxide" or oxygen or	EPO; JPO;	14:15
		"o.sub.2")) and "low k"	IBM_TDB	
8	25837	(ammonia or NH3 or "NH.sub.3") with (CO	USPAT;	2003/04/20
, and the second		or "carbon monoxide" or oxygen or	EPO; JPO;	14:44
		"o.sub.2")	IBM_TDB	
9	82	((ammonia or NH3 or "NH.sub.3") with (CO	USPAT;	2003/04/20
		or "carbon monoxide" or oxygen or	EPO; JPO;	14:44
		"o.sub.2")) same (etch\$3 or remov\$3)	IBM_TDB	
		same dielectric	USPAT;	2003/04/20
10	1	6326302.pn.	EPO; JPO;	14:37
			IBM TDB	1 *****
1		((ammonia or NH3 or "NH.sub.3") with (CO	USPAT;	2003/04/20
11	1908	or "carbon monoxide" or oxygen or	EPO; JPO;	14:38
		"o.sub.2")) and (etch\$3 or remov\$3) and	IBM TDB	
		dielectric		
12	40676		USPAT;	2003/04/20
12	100/6	(nitrogen or N2 or "N.sub.2")	EPO; JPO;	14:49
		(III of ogen of the of the ogen of	IBM TDB	
13	160	((ammonia or NH3 or "NH.sub.3") with	USPAT;	2003/04/20
1 13	100	(nitrogen or N2 or "N.sub.2")) same	EPO; JPO;	14:45
		(etch\$3 or remov\$3) same dielectric	IBM_TDB	